Low-loss GHz frequency phononic integrated circuits in Gallium Nitride for compact radio-frequency acoustic wave devices

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Guiding and manipulating GHz frequency acoustic waves in µm-scale waveguides and resonators opens up new degrees of freedom to manipulate radio frequency (RF) signals in chip-scale platforms. A critical requirement for enabling high-performance devices is the demonstration of low acoustic dissipation in these highly confined geometries. In this work, we show that gallium nitride (GaN) on silicon carbide (SiC) supports low-loss acoustics by demonstrating acoustic microring resonators with frequency-quality factor (fQ) products approaching 4×10^{13} Hz at 3.4 GHz. The low dissipation measured exceeds the fQ bound set by the simplified isotropic Akhiezer material damping limit of GaN. We use this low-loss acoustics platform to demonstrate spiral delay lines with on-chip RF delays exceeding 2.5 µs, corresponding to an equivalent electromagnetic delay of ≈ 750 m. Given GaN is a well-established semiconductor with high electron mobility, our work opens up the prospect of engineering traveling wave acoustoelectric interactions in µm-scale waveguide geometries, with associated implications for chip-scale RF signal processing.

I. Introduction

Gigahertz (GHz) frequency acoustic wave devices underpin a variety of critical classical and quantum information processing technologies, ranging from RF filters in modern smartphones [1] to the development of quantum transducers for interconnecting remote superconducting qubit-based processors [2, 3]. Building on developments in (silicon) photonic integrated circuits on low-loss onchip routing and manipulation of light at telecommunication wavelengths ($\lambda_o \approx 1550 \, \mathrm{nm}$) in sub-µm waveguides and resonators [4], there has been a general trend towards extending the same degree of control towards high-frequency acoustic waves [5], given the similarity in wavelength ($\approx 1 \, \mu \text{m}$) between the two fields. In a piezoelectric material, the acoustic wave is usually generated from an RF signal of interest, and therefore, manipulating acoustic waves in chip-scale platforms provides new degrees of freedom for RF signal manipulation, ranging from exploiting non-reciprocity in RF signal processing [6] to the development of integrated front-ends that can support full duplex wireless protocols [7].

To realize their full potential, especially from an RF systems perspective, these GHz phononic integrated circuits (PnICs) platforms [8–10] need to achieve end-to-end insertion losses that are comparable to traditional bulk and surface acoustic wave devices [11–14]. This requires addressing two key challenges: (i) showing that GHz acoustic waves can be focused into and out of µm-scale waveguides with near unity efficiency [10, 15], and (ii) demonstrating that acoustic waves can be routed in these µm-scale waveguide geometries with negligible excess dissipation and scattering.

In this work, we focus on the second problem and demonstrate that high-frequency (> 3 GHz) acoustic waves can be guided with negligible excess dissipation and scattering in GaN PnICs. We use GaN-on-SiC [10] as our platform of choice for these experiments. GaN, in contrast to traditional acoustic wave devices [14] which exploit stronger piezoelectric insulators like scandium aluminum nitride (ScAlN) and lithium niobate (LN), is a moderate piezoelectric semiconductor with high electron mobility [16]. This combination opens up the possibility of engineering acoustoelectric interactions in µm-scale waveguide geometries [17, 18], enabling tight integration between passive acoustic components and active semiconductor devices on the same die. We would like to note here that while the idea of guiding acoustic waves in waveguides is not new [19], and 1D wave confinement has been exploited in commercial devices [20, 21], our main focus here is on waveguide geometries with strong transverse confinement with waveguide dimensions $\sim \lambda_a^2$, where λ_a is the acoustic wavelength, analogous to silicon integrated photonics.

We show that GaN-on-SiC acoustic microring resonators can achieve figures of merit, represented by the fQ product of the resonator [14], of 4×10^{13} Hz at 3.4 GHz operating frequency at ambient conditions in our best devices. This fQ product exceeds the isotropic Akhiezer damping limit (AKE) of GaN [22, 23], which provides a rough upper bound on the achievable quality factor at a given operating frequency. By relying on whispering gallery modes, which use the total internal reflection of sound for acoustic confinement, it is possible to minimize the excess acoustic dissipation and scattering. Furthermore, the fundamental material limited quality factors can be achieved while maintaining all the advantages of tight (µm-scale) confinement and manipulation in a guided wave geometry. We harness this low on-chip propagation loss to demonstrate integrated spiral delay lines that achieve RF signal delays of 2.5 µs, corresponding to

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an equivalent electromagnetic delay of $\approx 750\,\mathrm{m}$. Provided the insertion loss problem (i, above) can be similarly addressed through the design of efficient µm-scale focusing transducers [10, 15], our work opens up the possibility of re-thinking RF systems from the ground up around PnICs.

II. Microring resonators with fQ products approaching the Akhiezer damping limit

Figure 1(a) shows an optical microscope image of a fabricated four-port symmetric acoustic microring resonator. 3.4 GHz Lamb waves are launched into acoustic waveguides using focusing interdigitated transducers (IDT, P1-4) [10]. The acoustic waveguides are sidecoupled to the microring resonator, and nominally identical focusing IDTs are fabricated to act as acoustic receivers in the through, cross, and drop ports (labeled P1, P2, P3, and P4 in Fig.1(a)). The device is fabricated on a GaN-on-SiC wafer sourced from IQE with a thin (<50 nm) aluminum nitride (AlN) buffer layer. The GaN layer is iron doped to make it insulating. The fabrication process is similar to our previous work [10], and employs a multi-layer aligned electron beam lithography process to define the waveguides and IDT. The reactive ion etching and cleaning steps have been optimized to minimize surface roughness and sidewall residue in order to reduce the overall scattering loss in the waveguides.

The IDT electrode period (λ_a) , the GaN layer thickness (t_{wvq}) , and the waveguide (and ring resonator) width (w_{wvg}) are kept constant across all devices at 1.6 μm, 1.5 μm, and 1.8 μm, respectively. With a view towards achieving critical coupling [24] between the waveguide and the resonator, the waveguide resonator gap (g_{wvg}) is varied from 500 nm to 800 nm in 100 nm steps for a fixed coupling length (L_{cp}) of $2\lambda_a$, and the L_{cp} is varied from $2\lambda_a$ to $10\lambda_a$, in $4\lambda_a$ steps for a constant g_{wvg} of 500 nm. Figure 1(b) shows the measured through-port transmission spectrum (S_{21}) of a representative device with a radius (R) of 115 µm, $L_{cp} = 2\lambda_a$, and $g_{wvg} =$ 500 nm. The transmitter and receiver IDT characteristics are also shown in the overlaid RF reflection (S_{11}) spectra. While the IDTs are nominally designed to be identical, the measured characteristics are different due to fabrication imperfections, mainly substrate charging and proximity error correction effects. The main features of interest are the sharp dips (indicated by the red arrow in Fig.1(b)) that correspond to successive acoustic whispering gallery resonances of the microring resonator.

The acoustic transmission spectrum of the device in both the through and drop ports is plotted again (in linear scale), in Fig.2(a), showing good correspondence between the frequencies of the dips in the through-port and the peaks in the drop-port, as expected. The inset in Fig.2(a) shows a zoomed-in spectrum of one of the modes of interest, clearly showing a doublet. In keeping with the optics analogy [25], the appearance of doublets

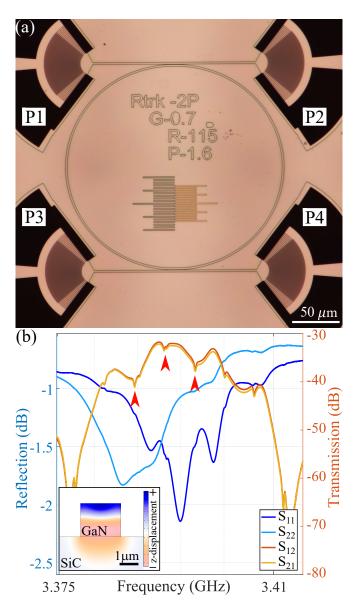


FIG. 1. (a) Optical image of 4-port ring device, with a ring radius (R) of 115 µm, 700 nm (g_{wvg}) spacing between waveguide and ring, and coupling length (L_{cp}) of $2\lambda_a$. IDTs' period (λ_a) is 1.6 µm while waveguides' and ring's width (w_{wvg}) are 1.8 µm and GaN thickness (t_{wvg}) is 1.5 µm, (b) Frequency spectrum of a 4-port device with ring R=115 µm, an $L_{cp}=2\lambda_a$, and $g_{wvg}=500$ nm. The transmission $(S_{21}$ and $S_{12})$ and reflection $(S_{11}$ and $S_{22})$ of ports P1 and P2 are presented in the log-scale. The red arrows highlight the ring dips and the inset presents the Lamb wave mode profile.

in the transmission spectrum is usually an indicator of the presence of high-quality factor (Q) modes in the system. We estimate the Q of the modes using a Lorentzian lineshape fit [26] to the (power) spectrum and estimate a loaded Q of 9,963 with a 5% fitting error. We find high Q modes across a wide variety of devices, as indicated in Fig.2(b). The data points reported in our previous work [10] are also indicated to show the improvement

in Q, obtained through fabrication optimization. The highest Q measured in these devices at ambient conditions is 11,710. This corresponds to an fQ product of $3.98 \times 10^{13}\,\mathrm{Hz}$, which is by far the highest reported in the GaN material platform as shown in Fig. 3. Such high Q's point to the importance of designing acoustic resonators around whispering gallery modes with the total internal reflection of sound, rather than relying on metallic boundaries or grating reflectors, which always provide excess dissipation and scattering, especially at GHz frequencies.

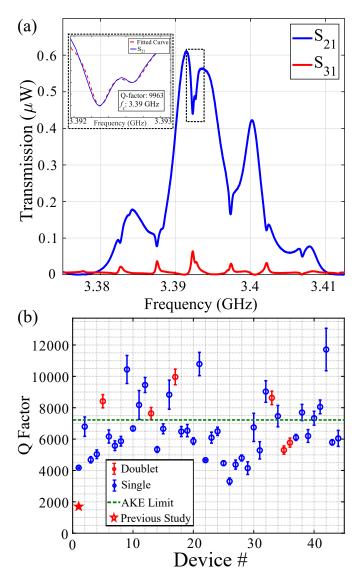


FIG. 2. (a) Transmission spectrum of a 4-port device with ring R=115 µm, an $L_{cp}=2\lambda_a$, and $g_{wvg}=500$ nm. The transmission of through (blue) (S_{21}) and drop (red) (S_{31}) are presented in linear scale. The Q-fitting of the doublet ring dips is presented in the inset. The red dash curve presents the fitting while the solid blue line presents the data highlighted with the dashed box, (b) Q factors of our fabricated devices with the fitting error indicated with bars. The green line indicates the GaN Akhiezer fQ limit for a frequency of $3.4\,\mathrm{GHz}$.

To provide some context on the ultimate dissipation limits and the prospects for future improvement, it is instructive to compare the Q factors achieved in these experiments with the fQ bounds set by AKE in GaN [22, 23]. We use a simplified expression for the AKE limit that is applicable to isotropic media at a given frequency $(\omega = 2\pi f)$:

$$fQ = \frac{\rho v_a^2 (1 + (\omega \tau)^2)}{2\pi \gamma^2 C_v T \tau} \tag{1}$$

where the material parameters and their corresponding values for GaN and SiC [16]) are presented in Table I.

The use of the AKE limit ($\omega \tau \ll 1$) to bound the dissipation is appropriate for the device frequencies (< 4 GHz) considered in this work because the relevant phonon scattering time (τ) for GaN is estimated to be $2.02 \,\mathrm{ps}$ [16]. Figure 3 plots the measured Q of our device, along with a few other GHz frequency acoustic resonators in GaN from the literature. We overlay the estimated AKE limit for both GaN and SiC using equation 1. As can be seen, the devices reported in this work show the highest fQ products by far for any reported GaN devices, and the best-performing devices exceed the AKE limit of GaN, as expressed by equation 1. We would like to note here that the AKE limit as expressed by equation 1 should be interpreted more as a rough estimate for the dissipation and not a hard bound on the achievable quality factors as some of the assumptions underlying equation 1, in particular, isotropic material parameters and mode independent dissipation [30], are not true of the devices here.

While equation 1 is a simplification, an interesting question to ponder is why the Q factors of the devices in this work even approach the AKE limit in the first place, given that the interface between GaN and SiC is known to have threading dislocations due to lattice mismatch. We believe this is currently due to a combination of two factors: (a) the size (density contrast) of the threading dislocations is deeply sub-wavelength (< 8 nm compared to the acoustic λ_a of 1.6 µm), and their density is very low ($\approx 10^8 \text{ cm}^{-2} \sim 1 \text{ µm}^{-2}$) in these high-quality GaN-on-SiC substrates, which results in minimal acoustic wave-dislocation interaction and scattering, and (b) a fraction of the mode's acoustic energy (mode shape shown in Fig.1(b) inset) resides in SiC which has one of the highest fQ products amongst known materials [23]. We believe the high fQ products measured here more accurately reflect a weighted average between the GaN and SiC values as indicated in the inset in Fig.1(b), although this needs to be confirmed experimentally.

In addition to high Q, the PnIC micro-rings, from an RF systems perspective, it is equally important to operate these microrings near critical coupling, wherein the coupling rate from the waveguide to the resonator equals the intrinsic decay rate as the sound propagates in the ring [24]. For the fabricated devices reported in this work, we are currently operating in an under-coupled regime.

| Material Property | GaN | SiC | Units | Ref. |
|---|----------------------|-----------------------|-------------------|----------|
| Mass density (ρ) | 6150 | 3210 | kg/m^3 | [27] |
| Specific heat (C_s) | 490 | 750 | J/kg K | [27] |
| Electron mobility (bulk) (μ) | 200 | 400 | $\rm cm^2/Vs$ | [27] |
| Free electron concentration (N) | 5×10^{15} | _ | ${ m cm}^{-3}$ | [28] |
| Coupling coefficient (\mathbf{k}^2) | 0.02 | 8×10^{-4} | _ | [16] |
| Dielectric constant (ϵ_r) | 9.5 | 9.66 | _ | [27] |
| Phonon relaxation time (τ) | 2×10^{-12} | _ | s | [16] |
| Thermal conductivity (κ) | 130 | 360 | W/m - K | [27] |
| Linear expansion coefficient (χ) | 5.6×10^{-6} | 2.77×10^{-6} | K^{-1} | [27] |
| Acoustic velocity (v_a) | 7960 | 13300 | m/s | [22, 27] |
| Grüneisen parameter (γ) | 1.18 | 0.3 | _ | [23, 29] |

TABLE I. Wurtzite GaN and SiC material properties used for AKE limit calculation in equation 1

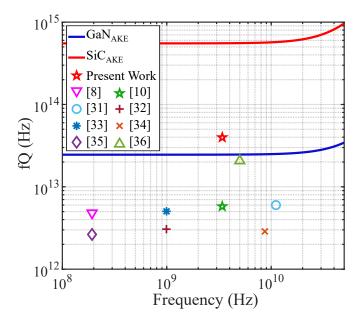


FIG. 3. Akhiezer fQ limit of SiC and GaN materials indicated in red line and blue line, respectively, and some of the reported GaN fQ values in the literature [8, 10, 31–36]. The references are placed in the main text. The maximum fQ product device is reported in this study and it is indicated with the red star $(3.98 \times 10^{13} \, \text{Hz})$ while the fQ product of the previous study is indicated with the green star.

Using temporal coupled mode theory [37], we can relate the measured device Q in the drop port (S_{31}) to the resonator's intrinsic Q (Q_i) , the waveguide Q (Q_w) that captures the resonator waveguide coupling, and the overall signal transmission magnitude, see Appendix A for derivation.

$$S_{31}(\omega_0) = \frac{P_{drop}}{P_{in}} = \left(\frac{Q}{Q_w}\right)^2 = \left(\frac{Q_i}{Q_w + Q_i}\right)^2 \quad (2)$$

Equation 2 enables us to estimate Q_i and Q_w by extracting Q and S_{31} from the experimental data:

$$Q_w = \sqrt{\frac{Q^2}{S_{31}(\omega_0)}} \tag{3}$$

$$Q_i = \frac{QQ_w}{Q_w - Q} \tag{4}$$

The fitted Q_s and calculated Q_i and Q_w of the microring with three different coupling lengths (L_{cp}) are given in Table II. From the table, we can see $Q_w >> Q_i$ which means the microrings are heavily under-coupled for our current waveguide resonator gaps (g_{wvg}) of 500 nm. The reduction in Q_w with increasing L_{cp} also verifies this. Based on FEM simulations, we estimate $g_{wvg} \approx 100$ nm and $L_{cp} \approx 71\lambda_a$ to achieve critical coupling in these devices. The lack of an evanescent acoustic field in the air makes critical coupling more challenging to achieve in PnICs than their photonic counterparts, although the geometries are well within reach of modern nanofabrication methods.

| | Fitted Q | Q_i | Q_w | L_{cp} | α |
|---|------------|-------|----------|---------------|-------------------------|
| | 9963 | 10043 | 124,538 | $2\lambda_a$ | $2.4\mathrm{dBmm^{-1}}$ |
| l | 6446 | 6495 | 846, 340 | $2\lambda_a$ | $3.7 dB mm^{-1}$ |
| İ | 6256 | 6314 | 655, 592 | $6\lambda_a$ | $3.8 dB mm^{-1}$ |
| l | 4455 | 4505 | 398, 440 | $10\lambda_a$ | $5.4 dB mm^{-1}$ |

TABLE II. Calculated Q, Q_i , Q_w , and loss parameter (α) , for 3 different coupling lengths of $2\lambda_a$, $6\lambda_a$, $10\lambda_a$, and for the doublet presented in Fig.2(a).

III. Integrated acoustic spiral delay lines with \approx 2.5 μs on-chip signal delays

As a demonstrator application for this low-loss PnIC platform, and to show the potential of being able to route GHz sound waves in μ m-scale on-chip waveguides, we build long spiral delay lines that can achieve $> 2.5 \,\mu$ s RF

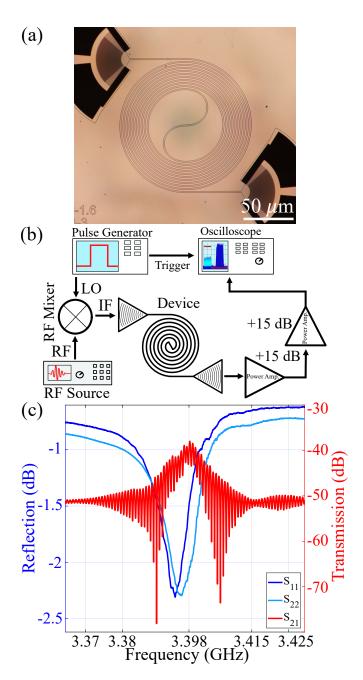


FIG. 4. (a) Optical image of a GaN spiral delay line with a 5.5 mm spiral length and 3 µm gap between successive turns of the spiral. The IDTs both have a 1.6 µm period and an angular span of 90°. (b) Schematic of the time-domain measurement setup. The RF signal from a signal generator at the IDT frequency is shaped by mixing with a pulse of a variable period, pulse width, and duty cycle. The shaped signal is sent to the transmitter IDT, propagates through the delay line, and is picked up by the receiver IDT. It is amplified and displayed on a high-speed oscilloscope. The scope is triggered by the pulse generator for synchronization of the time scans. (c) Measured S-parameter spectra through one of the spiral delay lines using a VNA. The transmission (S_{21}) and reflection $(S_{11} \text{ and } S_{22})$ are indicated in red, blue, and light blue colors. The spiral length was 4.1 mm and the peak transmission was $\approx -38\,\mathrm{dB}$ at a transmission frequency of $\approx 3.4\,\mathrm{GHz}$.

signal delays in a compact chip-scale footprint. Given that the speed of sound is $\approx 10^{-5}$ the speed of light, acoustic delay lines provide a practical route toward achieving large RF delays ($\gg 100$ ns) in chip-scale platforms. Acoustic delay lines have a long history in signal processing [12, 38], and are recently undergoing a resurgence with the development of new piezoelectric platforms like LN on insulator [39], which can support waveguiding using suspension. As outlined above, the GaN platform's main advantage is the prospect of integrating signal processing circuitry on the same die and exerting dynamic control on sound waves in µm-scale geometries by exploiting acoustoelectric interactions.

Figure 4(a) shows an optical microscope of a fabricated spiral delay line with a length of 5.5 mm. Focusing IDTs similar to the ones used in the microring resonator experiment described above, are used to launch and detect 3.4 GHz Lamb waves into and out of the spiral waveguide. The measured RF transmission (S_{21}) through the spiral waveguide ($L_{sp} = 4.1 \,\mathrm{mm}$), along with the IDT characteristics (S_{11}, S_{22}) are shown in Fig.4(c). The transmission spectrum is clearly peaked at the IDT S_{11} dips showing acoustic wave transmission through the length of the spiral. We can also verify that the acoustic wave makes its way all the way to the center of the spiral and out (and eliminate leaky modes and direct cross-talk), by fabricating spirals with the central connection missing. Appendix C shows that the signal transmission S_{21} drops to the vector network analyzer (VNA) noise floor and serves as our control experiment. An interesting feature of the transmission spectrum for the intact spiral in Fig.4(c) is the presence of sharp periodic dips (zoomed-in image in Fig.6), which are due to an unintended acoustic Fabry-Perot cavity being set up inside the spiral delay line due to reflections. Estimating the free spectral range (Δf) from the transmission and using the group velocity of the Lamb waves in the resonator (from the delay measurement Fig.5) (v_g) , we estimate the cavity length $(L_{cav} = v_q/2\Delta f)$ to be $\approx L_{sp}/2$.

Figure 4(b) shows the measurement setup used to perform the time delay measurements using the acoustic spiral delay lines [40]. A continuous wave RF signal from a signal generator (at the IDT frequency) is mixed with a short pulse from a pulse generator. This pulsed signal is sent to the transmitter IDT, where it gets converted to sound and is launched into the spiral waveguide. At the output of the spiral waveguide, a nominally identical IDT converts the acoustic signal into an electrical signal, which is amplified and fed to a high-speed oscilloscope. The scope trace is triggered by the pulse generator to synchronize the scans and allow for averaging to improve the received signal-to-noise ratio. In our experiments, we use a pulse width of 1 µs and a repetition rate of 100 kHz.

Figure 5 shows the measured delays from four different delay lines with spiral lengths varying from 4.2 mm to 8.2 mm, with the corresponding signal delays ranging from $1.4\,\mu s$ to $2.5\,\mu s$. The reference signal from the pulse generator is shown overlaid in red, and the received signal is

shown in a different color for each device. The scope trace for the received signals shows two components, a fast signal that is overlapped with the trigger which originates from (weak) electromagnetic radiation cross-talk between the transmitter and receiver IDTs, and a slower acoustic signal that arrives later that corresponds to sound propagating through the spiral waveguide. From the shape of the received signal compared to the input pulse, it is clear that the IDT and the spiral delay line in combination modify the shape of the transmitted pulse.

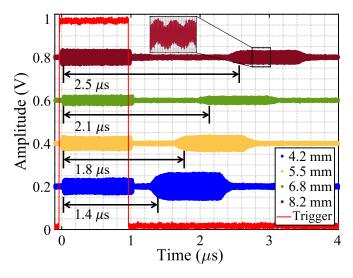


FIG. 5. RF signal delay measurements for delay lines with lengths of 4.2 mm (blue), 5.5 mm (yellow), 6.8 mm (green), and 8.2 mm (brown). The measured signal delays are 1.4 μ s, 1.8 μ s, 2.1 μ s, and 2.5 μ s, respectively. The input pulse is shown in red for reference.

As Figure 5 shows, the longest spiral delay lines provide an on-chip delay of $\approx 2.5 \, \mu s$, which corresponds to a free-space electromagnetic delay of $\approx 750 \, m$, or equivalently a coaxial cable delay of $\approx 520 \, m$, all within an on-chip foot-print $< 0.25 \, mm^2$, which shows the real promise of guiding sound in μm -scale waveguides. From the measured spirals S-parameter peak transmission (S_{21}) , we can estimate our on-chip propagation loss to be $\approx 3.6 \, dB \, mm^{-1}$, which agrees reasonably well with the loss values extracted from the microring resonator Q measurements in Table II.

The combination of the IDT and the spiral delay line has strong frequency dispersion which affects the received pulse shape, as shown in Fig.5. The shape of the received pulse is also sensitive to the frequency as shown in Fig.6 which presents the transmitted (S_{21}) signal through a spiral delay line of length 4.2 mm. The regular periodic dips corresponding to the unintended acoustic Fabry Perot cavity formed in the delay line can be clearly seen. To study the dispersive effects of the delay line system on the pulse shape, we perform the signal delay experiment shown in Fig.4(b), but now tune the frequency of the signal generator to different locations in the S_{21} spectrum, indicated by the colored arrows in Fig.6. The

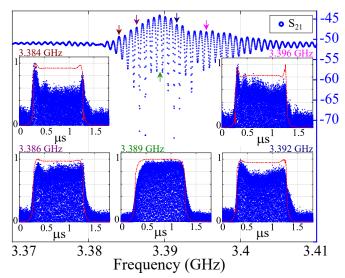


FIG. 6. Measured transmission (S_{21}) spectrum of a spiral delay line with 4.2 mm length. The insets show the received acoustic pulse shape as the input RF frequency is varied across the S_{21} spectrum with the frequency locations on the spectra indicated by colored arrows. The predicted pulse shape from linear response theory is overlaid in red, showing reasonable qualitative agreement with the measured results.

received acoustic pulse shape corresponding to each case is shown in the inset in Fig.6. As can be seen, the operating frequency has a significant effect on the received pulse shape.

To model the system response, we use methods from linear systems response theory [40] to decompose the input signal into its Fourier components, propagate each frequency component through the system and recombine at the output using an inverse Fourier transform to recover the time domain dynamics. We add an additional frequency-dependent loss term which allows us to replicate the observed qualitative time domain behavior, see Appendix B for further details. The frequency dependence of the loss term broadly follows the IDT spectral response, which indicates the relative efficiency with which the different frequency components are launched as propagating sound waves into the spiral waveguide. The strongly dispersive nature of these spiral delay lines and more generally, the strong geometric dispersion accessible in these µm-scale waveguide platforms provide new avenues for spectrum shaping and phase matching to harness acoustic nonlinear interactions like four-wave mixing [9].

IV. Conclusions

We have shown that GaN-on-SiC supports low loss GHz frequency acoustics in µm-scale waveguides and resonators with resonator loss measurements exceeding the isotropic material Akhiezer damping limit and long spiral delay lines with on-chip RF signal delays exceeding 2.5 µs. Given GaN's established technology base as a high electron mobility semiconductor, our work opens up the prospect of engineering traveling wave acoustoelectric interactions in waveguide and resonator geometries with associated implications for on-chip RF signal processing, in particular the implementation of novel wireless protocols like full-duplex wireless.

V. Acknowledgments

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Appendix A: Temporal Coupled-Mode theory for analysis of acoustic microring resonators

To quantify the waveguide resonator interaction in analogy with integrated photonics, we employ temporal coupled mode theory following the notation of [37]. A schematic of the add-drop waveguide coupled racetrack resonator is shown in Fig.7 denoting the various field amplitudes involved in the coupled mode equations described below.

Assuming a circulating field amplitude A in the resonator and S_i in the *i*-th waveguide port, we can formulate the standard coupled mode equations following [37]:

$$\frac{dA}{dt} = -i\omega_0 A - \frac{A}{\tau_d} - \frac{A}{\tau_p} - \frac{A}{\tau_i} + \sqrt{\frac{2}{\tau_p}} S_1 \tag{A1}$$

$$S_2 = S_1 + \sqrt{\frac{2}{\tau_p}} A \tag{A2}$$

$$S_3 = \sqrt{\frac{2}{\tau_d}}A\tag{A3}$$

where the τ_i represent the various decay channel time constants (intrinsic and coupling to top and bottom waveguides) and are related to the respective quality factors by $Q_i = \omega_0 \tau_i/2$.

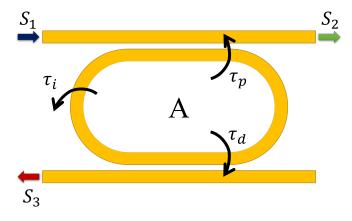


FIG. 7. An abstract diagram showing the critical components of the 4-port system. Single mode input into system S_1 , through output S_2 , and drop output S_3 . While field amplitude in the microring is A and τ_d , τ_p , and τ_i are the coupled decay rates from the cavity to through-port, drop-port, and the microring intrinsic loss, respectively.

For harmonic excitation at a frequency ω , we can solve these equations to extract the drop port (power) transmission S_{31} as:

$$T_{31}(\omega) = \frac{|S_3|^2}{|S_1|^2} = \frac{\frac{4}{\tau_p \tau_d}}{(\omega - \omega_0)^2 + (\frac{1}{\tau_d} + \frac{1}{\tau_c} + \frac{1}{\tau_c})}$$
(A4)

For simplification, we assume identical top and bottom waveguide decay rates $\tau_d = \tau_p = \tau_w/2$, where τ_w is the net waveguide decay lifetime. The total decay rate (expressed in lifetimes) and corresponding total Q are then:

$$\frac{1}{\tau_{cav}} = \frac{1}{\tau_w} + \frac{1}{\tau_i} \tag{A5}$$

$$\frac{1}{Q} = \frac{1}{Q_w} + \frac{1}{Q_i} \tag{A6}$$

In terms of these quantities, the drop-port transmission spectrum becomes:

$$T_{31}(\omega) = \frac{\frac{1}{4Q_w^2}}{\left(\frac{\omega - \omega_0}{\omega_0}\right)^2 + \frac{1}{4Q^2}}$$
(A7)

Now, we can analyze the Q_i and Q_w through the measured total Q and the peak transmission spectrum $(T_{31}(\omega_0))$:

$$T_{31}(\omega_0) = \left(\frac{Q}{Q_w}\right)^2 = \left(\frac{Q_i}{Q_w + Q_i}\right)^2 \tag{A8}$$

which leads us to

$$Q_w = \frac{Q}{\sqrt{T_{31}(\omega_0)}} \tag{A9}$$

$$Q_i = \frac{QQ_w}{Q_w - Q} \tag{A10}$$

Appendix B: Linear Response Theory for modeling spiral delay line transmission and dispersion

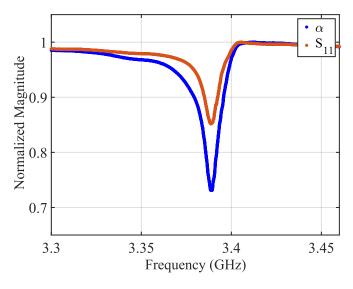


FIG. 8. Phenomenological α introduced into the model to fit the observed time domain pulse shapes.

To model the pulse shape of the received time domain signal that traverses the spiral delay line, we follow a standard procedure from linear systems analysis by decomposing the input signal into its constituent frequency components by a Fourier transform, propagating each component through the waveguide and recombining the signal at the received IDT by an inverse Fourier transform. The input is a pulsed RF signal $(H_i(t))$ of 1 µs pulse width and 3.4 GHz center frequency. The IDT is modeled as a frequency-dependent acoustic wave transducer that acts on each frequency component $(h_i(\omega))$ of the input signal according to its measured complex amplitude (voltage) reflection spectrum S_{11} , generating a corresponding acoustic wave amplitude $(u_i(\omega))$:

$$u_i = h_i(\omega)(1 - S_{11}(\omega)) \tag{B1}$$

The acoustic wave is propagated through the spiral waveguide and the output wave amplitude (u_o) can be represented as:

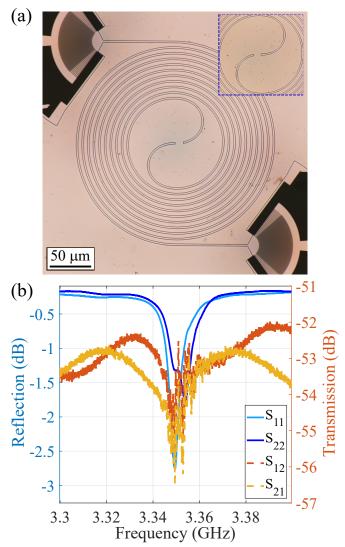


FIG. 9. The disconnected spiral delay line, (a) An optical image of the fabricated device, and the inset is the close look at the disconnected center of the spiral waveguide, (b) The measured S- parameters of the device, S_{21} and S_{12} are the transmission while S_{11} and S_{22} are the responses of transmitter and receiver IDTs.

$$u_o(\omega) = u_i(\omega)e^{i(\beta(\omega) + i\alpha(\omega))L_{sp}}$$
 (B2)

where β is the wave propagation constant, L_{sp} is the spiral waveguide length, and α is the propagation loss coefficient per unit length. To reproduce the measured pulse shapes, our $\alpha(\omega)$ is not a constant, but has the frequency variation as shown in Fig.8. The excess loss and the close mirroring of the IDT lineshape indicate that the acoustic power launched by the IDT off-resonance is not propagating, although this needs to be verified further.

At the receiving IDT, the signal amplitude $u_o(\omega)$ is reconverted back into the electrical domain $(h_o(\omega))$ us-

ing the receiving IDT spectrum $(S_{22}(\omega))$. Finally, the received signal $(h_o(\omega))$ is converted back into the time domain $(H_o(t))$ by an inverse Fourier transform. The red curves shown in Fig.6 in the main text are evaluated in this way. We would like to note here that the agreement between theory and experiment here is qualitative. While we are able to reproduce the received pulse shapes, the predicted signal amplitudes (red curves in Fig.6) have been scaled to fit the experimental data.

Appendix C: Disconnected Spiral Delay Line

To eliminate acoustic cross talk and leaky modes in the long spiral waveguide and to confirm the observation that the acoustic wave makes its way all the way to the center of the spiral and out, we fabricated a spiral delay line with a disconnected center. The broken center device is shown in Fig.9(a) and there is a 10 µm gap between two ends of the waveguide (inset of Fig.9(a)). The spiral waveguide is 5.9 mm long and IDTs have a 1.6 µm period. Figure 9(b) shows the measured IDT responses (S_{11} and S_{22}) which behave nominally as expected. The measured transmission spectra are however below -50 dB which is almost at the VNA noise floor (Fig.9(b)) and should be compared to the traces in Fig.4(c).

- [1] C. Lam, A review of the timing and filtering technologies in smartphones, in 2016 IEEE International Frequency Control Symposium (IFCS) (IEEE, 2016) pp. 1–6.
- [2] K. C. Balram and K. Srinivasan, Piezoelectric optomechanical approaches for efficient quantum microwave-tooptical signal transduction: The need for co-design, Advanced Quantum Technologies 5, 2100095 (2022).
- [3] J. C. Bardin, D. H. Slichter, and D. J. Reilly, Microwaves in quantum computing, IEEE Journal of Microwaves 1, 403 (2021).
- [4] L. Chrostowski and M. Hochberg, Silicon photonics design: from devices to systems (Cambridge University Press, 2015).
- [5] A. H. Safavi-Naeini, D. Van Thourhout, R. Baets, and R. Van Laer, Controlling phonons and photons at the wavelength scale: integrated photonics meets integrated phononics, Optica 6, 213 (2019).
- [6] A. Nagulu, N. Reiskarimian, and H. Krishnaswamy, Nonreciprocal electronics based on temporal modulation, Nature Electronics 3, 241 (2020).
- [7] A. Sabharwal, P. Schniter, D. Guo, D. W. Bliss, S. Rangarajan, and R. Wichman, In-band full-duplex wireless: Challenges and opportunities, IEEE Journal on Selected Areas in Communications 32, 1637 (2014).
- [8] W. Fu, Z. Shen, Y. Xu, C.-L. Zou, R. Cheng, X. Han, and H. X. Tang, Phononic integrated circuitry and spin—orbit interaction of phonons, Nature Communications 10, 1 (2019).
- [9] F. M. Mayor, W. Jiang, C. J. Sarabalis, T. P. McKenna, J. D. Witmer, and A. H. Safavi-Naeini, Gigahertz phononic integrated circuits on thin-film lithium niobate on sapphire, Physical Review Applied 15, 014039 (2021).
- [10] M. Bicer, S. Valle, J. Brown, M. Kuball, and K. C. Balram, Gallium nitride phononic integrated circuits platform for ghz frequency acoustic wave devices, Applied Physics Letters 120, 243502 (2022).
- [11] K.-y. Hashimoto, RF bulk acoustic wave filters for communications (Artech House, 2009).
- [12] S. Datta, Surface acoustic wave devices (Prentice Hall, 1986).
- [13] D. Morgan, Surface acoustic wave filters: With applications to electronic communications and signal processing (Academic Press, 2010).

- [14] H. Bhugra and G. Piazza, *Piezoelectric MEMS resonators* (Springer, 2017).
- [15] A. Siddiqui, R. H. Olsson, and M. Eichenfield, Lamb wave focusing transducer for efficient coupling to wavelengthscale structures in thin piezoelectric films, Journal of Microelectromechanical Systems 27, 1054 (2018).
- [16] M. Rais-Zadeh, V. J. Gokhale, A. Ansari, M. Faucher, D. Théron, Y. Cordier, and L. Buchaillot, Gallium nitride as an electromechanical material, Journal of Microelectromechanical Systems 23, 1252 (2014).
- [17] S. Ghosh, M. A. Hollis, and R. J. Molnar, Acoustoelectric amplification of Rayleigh waves in low sheet density Al-GaN/GaN heterostructures on sapphire, Applied Physics Letters 114, 063502 (2019).
- [18] L. Hackett, M. Miller, F. Brimigion, D. Dominguez, G. Peake, A. Tauke-Pedretti, S. Arterburn, T. A. Friedmann, and M. Eichenfield, Towards single-chip radiofrequency signal processing via acoustoelectric electronphonon interactions, Nature Communications 12, 1 (2021).
- [19] A. A. Oliner, Waveguides for acoustic surface waves: A review, Proceedings of the IEEE 64, 615 (1976).
- [20] T. Takai, H. Iwamoto, Y. Takamine, T. Fuyutsume, T. Nakao, M. Hiramoto, T. Toi, and M. Koshino, IHP SAW technology and its application to microacoustic components, in 2017 IEEE International Ultrasonics Symposium (IUS) (IEEE, 2017) pp. 1–8.
- [21] A. Hagelauer, R. Ruby, S. Inoue, V. Plessky, K.-Y. Hashimoto, R. Nakagawa, J. Verdu, P. de Paco, A. Mortazawi, G. Piazza, et al., From microwave acoustic filters to millimeter-wave operation and new applications, IEEE Journal of Microwaves (2022).
- [22] R. Tabrizian, M. Rais-Zadeh, and F. Ayazi, Effect of phonon interactions on limiting the fQ product of micromechanical resonators, in TRANSDUCERS 2009-2009 International Solid-State Sensors, Actuators and Microsystems Conference (IEEE, 2009) pp. 2131-2134.
- [23] S. Ghaffari, S. A. Chandorkar, S. Wang, E. J. Ng, C. H. Ahn, V. Hong, Y. Yang, and T. W. Kenny, Quantum limit of quality factor in silicon micro and nano mechanical resonators, Scientific Reports 3, 1 (2013).
- [24] A. Yariv, Critical coupling and its control in optical waveguide-ring resonator systems, IEEE Photonics Tech-

- nology Letters 14, 483 (2002).
- [25] D. Weiss, V. Sandoghdar, J. Hare, V. Lefevre-Seguin, J.-M. Raimond, and S. Haroche, Splitting of high-Q Mie modes induced by light backscattering in silica microspheres, Optics Letters 20, 1835 (1995).
- [26] P. J. Petersan and S. M. Anlage, Measurement of resonant frequency and quality factor of microwave resonators: Comparison of methods, Journal of Applied Physics 84, 3392 (1998).
- [27] V. Siklitsky, Semiconductors on nsm, Avaliable: http://www.matprop.ru/, accessed 2023-05-23 (1998).
- [28] L. C. Popa, Gallium nitride MEMS resonators, Ph.D. thesis, Massachusetts Institute of Technology (2015).
- [29] P. Perlin, C. Jauberthie-Carillon, J. P. Itie, A. San Miguel, I. Grzegory, and A. Polian, Raman scattering and X-ray-absorption spectroscopy in Gallium Nitride under high pressure, Physical Review B 45, 83 (1992).
- [30] S. S. Iyer and R. N. Candler, Mode-and directiondependent mechanical energy dissipation in single-crystal resonators due to anharmonic phonon-phonon scattering, Physical Review Applied 5, 034002 (2016).
- [31] I. Ahmed, U. Rawat, J.-T. Chen, and D. Weinstein, Super-high-frequency low-loss Sezawa mode SAW devices in a GaN/SiC platform, IEEE Transactions on Ultrasonics, Ferroelectrics, and Frequency Control 70, 291 (2023).
- [32] S. Wang, L. C. Popa, and D. Weinstein, GaN MEMS resonator using a folded phononic crystal structure, in *Proc. Solid-State Sens.*, *Actuators, Microsyst. Workshop (Hilton Head)* (2014) pp. 72–75.

- [33] I. Ahmed and D. Weinstein, Switchable transduction in Gan MEMS with off-state shunt, in 2021 IEEE 34th International Conference on Micro Electro Mechanical Systems (MEMS) (IEEE, 2021) pp. 978–981.
- [34] A. Ansari and M. Rais-Zadeh, An 8.7 GHz GaN micromechanical resonator with an integrated AlGaN/GaN HEMT, in *Proc. Solid-State Sens.*, Actuators, Microsyst. Workshop (2014) pp. 295–296.
- [35] Y. Xu, W. Fu, C.-l. Zou, Z. Shen, and H. X. Tang, High quality factor surface Fabry-Perot cavity of acoustic waves, Applied Physics Letters 112, 073505 (2018).
- [36] X.-B. Xu, J.-Q. Wang, Y.-H. Yang, W. Wang, Y.-L. Zhang, B.-Z. Wang, C.-H. Dong, L. Sun, G.-C. Guo, and C.-L. Zou, High-frequency traveling-wave phononic cavity with sub-micron wavelength, Applied Physics Letters 120, 163503 (2022).
- [37] J. D. Joannopoulos, S. G. Johnson, J. N. Winn, and R. D. Meade, *Photonic crystals: molding the flow of light* (Princeton University Press Princeton, NJ, 2008).
- [38] C. Campbell, Surface acoustic wave devices and their signal processing applications (Elsevier, 2012).
- [39] R. Lu, T. Manzameque, Y. Yang, and S. Gong, S0-mode lithium niobate acoustic delay lines with 1 dB insertion loss, in 2018 IEEE International Ultrasonics Symposium (IUS) (IEEE, 2018) pp. 1–9.
- [40] K. C. Balram, M. I. Davanço, B. R. Ilic, J.-H. Kyhm, J. D. Song, and K. Srinivasan, Acousto-optic modulation and optoacoustic gating in piezo-optomechanical circuits, Physical Review Applied 7, 024008 (2017).